### THE UNITED STATES PATENT AND TRADEMARK OFFICE

# REVOCATION AND NEW POWER OF ATTORNEY AND CHANGE OF CORRESPONDENCE ADDRESS

I, Dr. Graham Fisher, Director of Intellectual Property of MEMC Electronic Materials, Inc., the Assignee of the entire right; title, and interest in the U.S. Patent Application(s) and/or Patent(s) identified on the attached Schedule A, hereby revoke all previous powers of attorney or authorizations of agent given and do hereby appoint the attorneys or agents associated with the following Customer Number, with full power of substitution and revocation, to prosecute and transact all business in the Patent and Trademark Office connected therewith for the U.S. Patent Application(s) and/or Patent(s) listed in the attached Schedule A:

Customer Number: 76681

Please direct all correspondence in connection with said U.S. Patent Application(s) and/or Patent(s) to:

Customer Number: 76681

Respectfully submitted.

Date: 5/13/2008

Dr. Graham Fisher
Director of Intellectual Property
MEMC Electronic Materials, Inc.

### THE UNITED STATES PATENT AND TRADEMARK OFFICE

## STATEMENT UNDER 37 CFR 3.73(b)

MEMC Electronic Materials, Inc., a Delaware Corporation, pursuant to 37 CFR 3.73(b), hereby states that it is the Assignee of the entire right, title, and interest in U.S. Patent Application(s) and/or Patent(s) on the attached Schedule A.

The entire rights, title, and interest in the aforementioned Patent Application(s) and/or Patent(s) were conveyed to MEMC Electronic Materials, Inc. via Assignment(s) recorded with the United States Patent and Trademark Office at the Reel/Frame Numbers on the attached Schedule A.

The undersigned, Dr. Graham Fisher, Director of Intellectual Property, has full authorization to act on behalf of Assignee MEMC Electronic Materials, Inc.

Respectfully submitted,

Date: 5/13/2008

Dr. Graham Fisher

Director of Intellectual Property
MEMC Electronic Materials, Inc.

# APPENDIX A Owned by MEMC Electronic Materials, Inc.

ATTORNEY REFERENCE	CONF. NO	PUBLICATION NO. & DATE	SERIAL NO. FILING DATE	PATENT NO. ISSUE DATE	CURRENT OWNER/ ASSIGNEE	REEL AND FRAME NO.	ппе
EMC2554,1	6190	US-2002-0083889-A1 7/4/2002	10/073,506 2/11/2002	6,743,289	MEMO Electronic Materials, Ibc.	Division of 09/416,938 recorded at 010818/0877	THERMAL ANNEALING PROCESS FOR PRODUCING LOW DEFECT DENSITY SINGLE CRYSTAL SILICON
5MC2581	9880	US-2002-0134302-A1 9/26/2002	09/815,508 8/23/2061	6,579,382 6+17/2003	MEMO Electronic Materials, Inc.	011897/0283	HEAT SHIELD ASSEMBLY FOR CRYSTAL PULLER
EMC2583	9856		09:608,304 6/30/2000	6,435,474 6r20/2002	MEMC Electronic Materials, Inc.	91093810274	NON-CONTAMINATING GAS-TIGHT VALVE FOR SEMI- CONDUCTOR APPLICATIONS
EMG2607	5082		09/505,269 2/16/2000	6,479,386	MEMC Electronic Materials, Inc.	010883/0103	PROCESS FOR RECUBING SURFACE VARIATIONS FOR POLISHED WAFER
EMC2814	6202	US-2002-0007779-A1	09/475,326 12/30/1999	6,638,357 10/28/2003	MEMC Electronic Materials, Inc.	910588/0082	METHOD FOR REVEALING AGGLOMERATED INTRINSIC POINT DEFECTS IN SEMICONDUCTOR CRYSTALS
EMC2632	5009		09/502,340 2/10/2000	6,776,840	MEMC Electronic Materials, Inc.	010585/0457	METHOD OF CONTROLLING DIAMETER OF A SILICON CRYSTAL IN A LOCKED SEED LIFT GROWTH PROCESS
EMC2833	6689		09/489,481	6,316,828	MEMC Electronic Materials, Inc.	Continuation of 09/167,747 recorded at 009612/0586	CONTINUOUS OXIDATION PROCESS FOR CRYSTAL PULLING APPARATUS
EMC2840.1	9314	US-2003-0088421-A1 1/9/2063	09/989,200	6,485,992	MEMC Electronic Materials, Inc.	012B27/D404	PROCESS FOR MAKING WAFERS FOR ION IMPLANTATION MONITORING
EMC2641	4842		09,566,890 5/8/2000	6,444,027 9/5/2002	MEMC Electronic Materials, Inc.	011003/0198	MODIFIED SUSCEPTOR FOR USE IN CHEMICAL VAPOR DEPOSITION PROCESS
EMC2641.4	9780	US-2003-0041789-A1 3/6/2003	10/229,415 B/28/2002	6,652,650	MEMC Electronie Materials, Inc.	Continuation of 09/566,890 recorded at 01/1003/0198	MODIFIED SUSCEPTOR FOR USE IN CHEMICAL VAPOR DEPOSITION PROCESS
EMC2642	6444		09/723,847 11/28/2000	6,515,742 274/2003	MEMO Electronic Matenate, Inc.	011320/0948	DEFECT CLASSIFICATION USING SCALTERED LIGHT INTENSITIES
SMC2843	4588	US-2001-0037761-A1 11/8/2001	09/752,222 12/29/2000	6,596,095	MEMO Electronic Materials, Inc.	7120/239110	AN EPITAXIAL SILICON WAFER FREE FROM AUTODOPING AND BACKSIDE HALO AND A METHOD AND APPARATUS FOR THE PREPARATION THEREOF
EMC2844	4222		09/633,958	6,454,635	MEMO Electronia Materials, Inc.	011214/0312	METHOD AND APPARATUS FOR A WAFER CARRIER HAVING AN INSERT
EMC2851	6810		09/603,586	6,344,083 215/2002	MEMC Electronic Materials, Inc.	010783/0683	PROCESS FOR PRODUCING A SILICON MELT
EMC2841.4	2620	US-2002-0020339-A1 2/2/1/2002	905/05/60	6,652,645 11125/2003	MEMO Electronic Materials, Inc.	Continuation of 09/509,566 recorded at 010763/0683	Process for preparing a silicon melt
EMC2541.5	5192	US-2002-0083887-A1 7/4/2002	10/036,876 10/23/2001	6,749,683 6/15/2004	MEMC Electronic Materials, Inc.	01722/0302	PROCESS FOR PRODUCING A SELCON MELT
EMC2639	1082		09/521,525 3/2/000	6,350,312	MEMC Electronic Materials, Inc.	010884/0146 and 012139/0404	STRONTIUM DOPING OF MOLTEN SILICON FOR USE IN CRYSTAL GROWING PROCESS